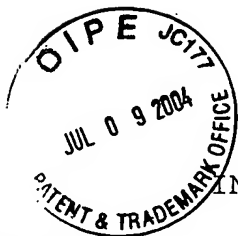


IFW



PATENT  
0283-0191PUS1

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: Hideo KIYOYAMA et al. Conf.: 2827  
Appl. No.: 10/811,804 Group: 1752  
Filed: March 30, 2004 Examiner: UNASSIGNED  
For: PROCESS FOR PREPARING LIGHT-SENSITIVE  
LITHOGRAPHIC PRINTING PLATE AND METHOD  
FOR PROCESSING THE SAME

L E T T E R

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

July 9, 2004

Sir:

Under the provisions of 35 U.S.C. § 119 and 37 C.F.R. § 1.55(a), the applicant(s) hereby claim(s) the right of priority based on the following application(s):

<u>Country</u>	<u>Application No.</u>	<u>Filed</u>
JAPAN	2003-093293	March 31, 2003

A certified copy of the above-noted application(s) is(are) attached hereto.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fee required under 37 C.F.R. §§ 1.16 or 1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

By 

Raymond C. Stewart, #21,066

RCS:anp  
0283-0191PUS1

P.O. Box 747  
Falls Church, VA 22040-0747  
(703) 205-8000

Attachment(s)